Relaxation of stress occurring in Cd–Ni diffusion zone with formation of intermetallic phase

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Relaxation of mechanical stress occurring in Cd–Ni diffusion zone was studied by metallographic methods. Brittle relaxation of tensile stress was revealed in Cd₀.₃₉Ni₀.₶₁ intermetallic phase growing in the diffusion zone. Evaluation of this stress made by the geometry of macroscopic cracks in the intermetallic phase showed values being by a factor 1.2 lower than stress values calculated by volume defect related with the intermetallic phase formation. As plastic deformation within the intermetallic phase is excluded, whereas brittle relaxation begins at the Cd₀.₃₉Ni₀.₶₁–Ni boundary, it was concluded that induced in Ni compressive stress relaxed by plastic deformation mechanism to the level of Ni elastic limit.

Keywords: intermetallic phase, diffusion zone, brittle relaxation, plastic deformation.

Metallographically, the process of relaxation of mechanical stresses, occurring in the diffusion zone of the system Cd–Ni, was investigated. It was found that the formation of the intermetallic phase Cd₀.₃₉Ni₀.₶₁ leads to a decrease in the stress values by a factor of 1.2 compared to the calculated values based on the volume of the defect. Since plastic deformation within the intermetallic phase is excluded, the relaxation of stress begins at the Cd₀.₃₉Ni₀.₶₁–Ni boundary. It was concluded that the stress induced in Ni is relaxed by a plastic deformation mechanism to the level of Ni elastic limit.

Relaxation of stresses that occur in the diffusion zone of the system Cd–Ni is studied. The formation of the intermetallic phase Cd₀.₃₉Ni₀.₶₁ leads to a decrease in the stress values by a factor of 1.2 compared to the calculated values based on the volume of the defect. Since plastic deformation within the intermetallic phase is excluded, the relaxation of stress begins at the Cd₀.₃₉Ni₀.₶₁–Ni boundary. It was concluded that the stress induced in Ni is relaxed by a plastic deformation mechanism to the level of Ni elastic limit.

1. Introduction

It is known that at higher temperatures in macroscopically inhomogeneous crystalline media, various relaxation processes take place; these are often accompanied by plastic deformation [1], diffusion [2, 3], and other transport phenomena [4] resulting in redistribution of substance and internal stress, change of dislocation structure, generation...
of pores and cracks, recrystallization, etc. To understand regularities of physical processes in complex systems, consistent analysis of rather simplified models is necessary which may be useful to construct the complex process under study.

One of the model conceptions is the problem on interdiffusion of two substances $A$ and $B$ with strongly different atomic sizes which are in diffusion contact by a flat boundary in the case where not solid solutions but ordered compounds of $A_mB_n$ type ($m$ and $n$ are integers) are formed. Such compounds occurring between two metals in the diffusion contact are named intermetallic phases.

Because generally a $A_mB_n$ compound has a crystalline structure different from both $A$ and $B$ structures, their specific volumes in $A$ and $B$ lattices are different from these in the $A_mB_n$ lattice. It is the main reason for appearing stress both in the intermetallic phase bulk and in neighboring areas of initial $A$ and $B$ components.

The deformation caused by the volume jump can be free realized only in the $OX$ direction (Fig. 1), whereas in $YZ$ plane it is hampered by mechanical adhesion between the intermetallic phase and initial components at interfaces; thus near interface boundaries, shearing stress $\sigma_{YZ}$ would act which sign and distribution depend on the ratio of specific volumes of atoms in each of contacting phases.

In Fig. 2, stress distribution near a $A$--$A_mB_n$ interphase boundary is shown for the case where $V_A > V_1$ ($V_A$ and $V_1$ are specific volumes of an $A$ atom in $A$ lattice and in intermetallic phase lattice, respectively). Near the interphase boundary, stress attain maximum values, and their sign changes abruptly from positive (compressive) to negative (tensile) in going from $A$ phase to $A_mB_n$ intermetallic one.

Evaluation of the maximum stress occurring in the intermetallic phase near the $A$--$A_mB_n$ interface can be made using a simple relation:

$$\sigma_{\text{max}} = G \frac{\Delta V_{A_1}}{V_A},$$

where $G$ is elastic modulus of an intermetallic phase, and $\Delta V_{A_1} = V_1 - V_A$.

If the stress level exceeds the elastic modulus of $A$ or $A_mB_n$ material, excess stress will relax by the mechanism of plastic deformation [4, 5]. Relaxation processes result in decreasing the stress level near interfaces down to elastic limit $\sigma_{el}$ (Fig. 3). As the stresses on both sides of the interface are opposite by sign, so, compensate each other, the steady state stress levels on the both sides are equal by absolute value and are determined by $\sigma_{el}$ of the phase with lower elastic limit.

Plasticity of a crystal is specified mainly by mobility and density of present dislocations. Necessity to retain a regular configuration in atomic arrangement decreases significantly the dislocation mobility and, consequently, reduces the ability to plastic relaxation of elastic energy in them. Therefore, tensile stress in intermetallic phases is able to relax by crack formation [6, 7]. In this way of stress relaxation we can evaluate them by arrangement and width of formed cracks.

As it is known, stress relaxation due to crack formation is realized in the area with a characteristic linear size close to the crack size [8]. Therefore, relaxation of tensile stress occurring, for example, in a layer of $A_mB_n$ intermetallic phase (Fig. 1) near a flat interface $A$--$A_mB_n$ (Fig. 3) may take place due to formation of a row of cracks (parallel to each other and perpendicular to the plane of the interface) which are distanced by $l$ being of the order of crack length (Fig. 4).
In assumption that the brittle fracture of an intermetallic phase with formation of cracks with ∆l width (Fig. 4) is the only mechanism of relaxing the stress (1) caused by the relative deformation ΔV/V₀, the deformation in the direction of crack opening (in our case, along Y axis) will be ∆l/l=1/3ΔV/V₀. Then the value of stress occurring in the intermetallic phase can be expressed as

$$\sigma_{\text{max}} = 3G\frac{\Delta l}{l}, \quad (2)$$

2. Relaxation processes in Cd–Ni diffusion zone

A rather convenient object for experimental studying the processes of brittle relaxation of tensile stress occurring in an intermetallic phase growing in the diffusion zone is Cd–Ni system which diffusion properties are well investigated [9, 10].

According to the equilibrium diagram [11], solubility in solid state is practically absent in Cd–Ni system. As a result interdiffusion between Cd and Ni plates contacting by a flat boundary, a layer of Cd₂Ni₅ intermetallic phase appears and grows; it has a cubic structure with unit cell parameter a₁ = 9.758 Å. The unit cell includes 52 atoms: 42 atoms of Cd and 10 atoms of Ni. The volume of the unit cell is V₁ = a₁³.

Cd has a hexagonal close-packed lattice with parameters a = 2.985 Å and c = 5.6206 Å. The unit cell is a body-centered right-angle prism with height c and rhomb base with side a. The volume of the unit cell is V₂ = ca²√3/2. The unit cell contains 2 atoms. Ni face centered cubic lattice has the parameter a₂ = 3.524 Å. The volume of the unit cell consisting of 4 atoms is V₃ = a³N₂.

The reaction of formation of a single Cd₂Ni₅ unit cell can be written as:

$$42\text{Cd} + 10\text{Ni} \rightarrow 2\text{Cd}_2\text{Ni}_5$$

or as

$$21\text{Cd} \text{ unit cells} + 2.5\text{Ni} \text{ unit cells} \rightarrow \rightarrow 1 \text{Cd}_2\text{Ni}_5 \text{ unit cell}.$$  

Therefore the relative deformation accompanying the formation of the intermetallic phase is:

$$\frac{\Delta V}{V_0} = \frac{V_1 - (21 \cdot V_{\text{Cd}} + 2.5 \cdot V_{\text{Ni}})}{21V_{\text{Cd}} + 2.5 \cdot V_{\text{Ni}}} = -0.09.$$  

Taking the elastic modulus of the intermetallic phase as G = 5·10¹⁰N·m⁻², we obtain the evaluation of tensile stress corresponding to this deformation:

$$\sigma_{\text{max}} - G \left| \frac{\Delta V}{V_0} \right| = 4.5 \cdot 10^6 \text{N} \cdot \text{m}^{-2}. \quad (3)$$

The process of stress brittle relaxation was studied by metallographic methods. Two-layer Cd–Ni samples were prepared: plane-parallel plates cut from cadmium and nickel bars were ground and polished. Then the plates were brought in contact by their polished surfaces and annealed isothermally at T = 280°C during about 10 h in the atmosphere of flowing hydrogen. After annealing, the sample was treated by metallographic polishing in the direction perpendicular to Cd–Ni contact plane. Structure of the intermetallic phase layer formed between Cd and Ni plates was studied by a metallographic microscope. A typical micrograph of this layer is shown in Fig. 5. Using an ocular micrometer, an average width ∆l of cracks formed in the intermetallic layer and a characteristic distance l between the cracks were measured.
3. Results and discussion

Experimental values of stress (which relaxation resulting in crack formation) were evaluated by Eq. (2):

$$\sigma_{\text{exp}} = 3G\frac{\Delta l}{l} = 3.75 \cdot 10^9 N \cdot m^{-2}.$$  

As it is seen, the level of experimentally measured stress acting in the intermetallic layer is by a factor 1.2 lower than the value obtained from Eq. (3) calculated by the relative deformation accompanying the formation of the compound. This fact, evidently, indicates their partial relaxation by the mechanism of plastic deformation. Because the action of this mechanism is excluded in the intermetallic layer, we have to assume that the stress rapid damping took place in the materials of initial components.

The shape and distribution of cracks in the intermetallic phase (Fig. 5) show that stress attains its maximum absolute value near the Ni–Cd$_2$Ni$_5$ interface. Hence, the stress plastic relaxation occurred in Ni$_5$ and the stress level calculated by the crack geometry in the intermetallic layer corresponds to the Ni elastic limit.

In [12, 13] intended to studying the influence of stress in the diffusion zone on the interdiffusion kinetics, the possibility of compressive stress plastic relaxation in Cd material during Cd$_2$Ni$_5$ layer growth. It was shown that the plastic relaxation results in lowering the stress down to $10^7$ N/m$^2$ (Cd elastic limit) at the Cd$_2$Ni$_5$–Cd boundary and changes significantly the Cd structure. Because no cracks occur in Cd$_2$Ni$_5$ on the Cd side, the Cd elastic limit, evidently, does not exceed the Cd$_2$Ni$_5$ ultimate strength.

4. Conclusions

Tensile stress occurring within the Cd$_2$Ni$_5$ layer formed in interdiffusion process in Cd–Ni system exceeds the compound ultimate strength and relaxes by the mechanism of crack opening. Comparative estimation of the stress value by the geometry of cracks and by the volume jump accompanying the compound formation shows that before opening the cracks in the intermetallic phase, partial relief stress takes place as a result of plastic deformation in initial materials.

As the plastic relaxation inside the intermetallic phase is excluded, whereas the stress brittle relaxation begins at the Cd$_2$Ni$_5$–Ni interface, the conclusion is made that the damping of induced compressive stress in Ni took place down to the Ni elastic limit by the mechanism of plastic deformation.

Evidently, the stress plastic relaxation occurred also in Cd material which elastic limit is lower than the intermetallic phase ultimate strength.

References

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